



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yoshitaka HAMADA et al.

Serial No.: 10/706,861

Filing Date: November 12, 2003

For: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND METHOD
FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM, AND
SEMICONDUCTOR DEVICE

VERIFICATION OF TRANSLATION

Honorable Commissioner of Patents and Trademarks

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Hidefumi KAWAMURA residing at c/o OKUYAMA & CO., 8th Floor,
Akasaka Noa Bldg., 2-ban 12-go, Akasaka 3-chome, Minato-ku,
Tokyo 107-0052, Japan declares:

(1) that he knows well both the Japanese and English
Languages;

(2) that he translated the attached specification and
claims of U.S. Patent Application Serial No. 10/706,861 from
Japanese to English;

(3) that the attached English translation is a true and
correct translation of the Japanese text filed on November 12,
2003 to the best of his knowledge and belief; and

(4) that all statements made of his own knowledge are
true and that all statements made on information and belief are
believed to be true, and further that these statements are made
with the knowledge that willful false statements and the like are
punishable by fine or imprisonment, or both, under 18 USC 1001,
and that such false statements may jeopardize the validity of the
application or any patent issuing thereon.

Date: June 18, 2004

Hidefumi KAWAMURA